ABSTRACT

The present invention provides a cleaning method and a device for a packaging structure. The cleaning method includes a negative pressure cleaning process, and the negative pressure cleaning process comprises: adjusting the pressure in a chamber where the packaging structure is located to a preset vacuum pressure; rotating the packaging structure; spraying a cleaning liquid at a preset temperature onto the rotating packaging structure to perform negative pressure cleaning on the packaging structure; wherein, the preset vacuum pressure is higher than the vaporization pressure of cleaning liquid at the preset temperature. The principle that the surface tension of cleaning liquid decreases under negative pressure is utilized to promote the flow of cleaning liquid in the tiny gaps of the packaging structure, and prevent the cleaning liquid from being vaporized before reaching a part to be cleaned of the packaging structure.